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Built-in voltage in thin ferroelectric PbTiO₃ films: the effect of electrostatic boundary conditions

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Abstract

PAPER

We have studied the built-in voltage in heterostructures composed of ferroelectric PbTiO₃ and dielectric spacers of SrTiO₃, grown on SrTiO₃ substrates with SrRuO₃ bottom electrodes. We used piezoresponse force microscopy to determine the domain structure of the samples and perform local switching experiments. By increasing the thickness of the $SrTiO₃$ spacer layers, we were able to tune the polarization configuration in the PbTiO₃ films by gradually going from a monodomain configuration to a polydomain one. The built-in voltage was found to be linked to the choice of electrodes and to the thickness of the spacer layer. The stability of artificially poled regions was also affected, with a faster back-switching for the samples with the thicker $SrTiO₃$ spacers. We have additionally compared samples with and without a top $SrRuO₃$ electrode, showing that a top electrode layer results in a stronger built-in voltage, responsible for a preferential monodomain configuration and a very fast back-switching of artificially poled regions.

General description of effective screening/depolarization field and built-in field

Given the recent progress in the growth of oxide heterostructures and ultrathin films, it is possible to create artificially layered materials with atomically precise interfaces. In such systems, the effects of these interfaces, and of the surface, are extremely important [[1](#page-11-0)], motivating the ongoing search for novel phenomena appearing and the exponential growth of the field of oxide interface engineering [[2](#page-11-1), [3](#page-11-2)]. In electronic devices based on functional oxides, and in particular on ferroelectrics, the interface between the oxide thin film and the electrode(s) is also crucial from a technological viewpoint. For novel device concepts such as ferroelectric tunnel junctions and memristors[[4](#page-11-3)–[8](#page-11-4)], understanding and quantifying the effects of the electrostatic boundary conditions in nanoscale ferroelectrics is becoming more important than ever.

It is well established that the switching properties of ferroelectric films depend on the specific ferroelectricelectrode system chosen [[9](#page-11-5)], and that polarization stability is determined by the screening of surface/interface bound charges[[10](#page-12-0)]. The origin of this dependence of the ferroelectric state of a thin film on the electrostatic boundary conditions is linked to Fermi level alignment and related band-bending, depletion region, space charge, and other phenomena. Other factors can play a role too. For example, it was shown by Stengel et al that ferroelectricity can be either destabilized or enhanced at metal-oxide interfaces, depending on the stiffness of the electrode-oxide bonds[[11](#page-12-1)]. All these effects result in built-in voltages and depolarization fields that affect the stability of the polarization and the intrinsic domain structure [[12](#page-12-2)].

The built-in voltage leads to a built-in field whose intensity depends on the ferroelectric film thickness. Considering the 'intrinsic' ferroelectric energy double well and polarization-electric field (P-E) loop illustrated in figure [1](#page-2-0) (red), the built-in field asymmetrizes the energy double well, leading to a favored polarization direction, and shifts the P-E loop horizontally (green).

The depolarization field, produced by imperfectly screened surface bound charges, becomes important as the film thickness is reduced. This field depends on the effective screening length of the particular interface $\lambda_{\rm eff}$, on the ferroelectric film thickness d, and on the polarization P as [[13](#page-12-3)] $E_d = \frac{P \cdot \lambda_{\text{eff}}}{\epsilon_0 \cdot d}$. This depolarization field is always oriented opposite to the polarization, thus destabilizing the polarization state, making the energy double-well shallower and reducing the opening of the P-E loop (figure [1-](#page-2-0)blue). Considered most of the time as detrimental to the properties of ferroelectric thin films, it can have the positive effect of reducing the voltage needed to switch the polarization [[14](#page-12-4)].

We recently studied the effect of introducing dielectric layer spacers between ferroelectric thin films and the electrode layers[[12](#page-12-2)]. The main idea was to use these dielectric layers (made of $SrTiO₃$) as a way to tune the effective screening length and thus the depolarization voltage and field. Using piezoresponse force microscopy (PFM), we could show that the domain structure evolves from monodomain for PbTiO₃ films grown on SrTiO₃ substrates with an $SrRuO₃$ electrode without dielectric spacers, to polydomain as the spacer layer thickness is progressively increased to a few nanometers. Here, we use the same approach to investigate the effect of electrodes and spacer layers on the built-in voltage and field. The samples studied are PbTiO₃ thin films of varying thicknesses (up to 50 nm), grown on $SrTiO₃$ substrates with a bottom $SrRuO₃$ electrode of 22 nm. Two series of samples were produced, one without a top electrode, where surface adsorbates are the source of screening, and one with a top $SFRuO₃$ electrode. For both series, we have used $SrTiO₃$ top and/or bottom spacer layers of different thicknesses(from 0 to 10 unit cells, i.e. 4 nm). To probe the built-in voltage in both types of samples and study the effect of the spacer layer thickness on the intrinsic domain configuration and on the domain stability, we have used PFM coupled with structural characterization. Our observations demonstrate that both mechanisms, i.e. the built-in voltage and the depolarization field, can play a role simultaneously, with a progressive change from a state where the intrinsic domain configuration is governed by the internal bias field towards a state where the domain configuration is governed by the depolarization field alone, on increasing the spacer layer thickness(see Supporting Information for more details).

Determination of the built-in voltage

To estimate the built-in voltage in our samples, we performed local switching measurements using PFM [[15](#page-12-5)– [17](#page-12-6)]. Amplitude and phase signals were recorded using an Asylum Research Cypher atomic force microscope (AFM) operating in dual resonance tracking (DART) mode [[18](#page-12-7)], while a DC voltage V_{DC} was ramped between the top and bottom electrodes. For samples without a top electrode layer, the conducting tip itself served directly as a top electrode. For samples with a top electrode layer, the voltage was simultaneously applied to the top electrode (via an external wire) and to the tip, in order to avoid any electrostatic effect. One advantage of this technique over techniques based on the integration of switching currents is that it is much less sensitive to leakage.

Built-in voltage in samples without a top electrode layer

On the series of samples without a top electrode layer, the built-in voltage was measured using switching spectroscopy piezoresponce force microscopy (SSPFM), as described in [[19](#page-12-8)]. The set-up is represented in

The phase displays the expected hysteresis loop, with the butterfly loop for the amplitude, showing a built-in voltage of 1.6 V. By repeating these measurements at different locations on a sample, a grid is obtained allowing the evaluation of the averaged built-in voltage of the sample (d). The values are quite homogeneous, except for a spot on the top right, which could be explained by the presence of an impurity on the sample surface.

figure [2](#page-3-0)(a): a DC bias V_{DC} is applied to the AFM tip in addition to the AC probing voltage V_{AC} , and the bottom electrode is grounded. The PFM phase and amplitude are then recorded while the DC bias is ramped stepwise, going back to zero bias after each step, as schematically shown in figure [2](#page-3-0)(b). This produces two measurements: one as a function of the bias applied at the time of the acquisition ('on'), and one as a function of the bias applied just before the acquisition ('off'). To avoid effects of electrostatic interactions between tip and sample, only the results of the 'off'state are used. This produces the typical loop shape for the phase, and a butterfly shape for the amplitude as shown on figure [2](#page-3-0)(c) for a 50 nm PbTiO₃ film with a 2 nm top SrTiO₃ spacer and a 22 nm SrRuO₃ bottom electrode. To make our measurements more reliable, they were repeated a large number of times on a grid (typically at least 16 \times 16 points evenly spaced on a 2 \times 2 μ m² grid). The switching biases were then extracted as the points of lowest amplitude, and used to calculate the built-in voltage for each point, corresponding to the value of $V_{\rm DC}$ at the center of the loop 1 1 . An example of such a grid of values is shown in figure [2](#page-3-0)(d).

The phase and amplitude loops are all systematically shifted towards positive bias, corresponding to a residual field in the ferroelectric layer pointing up, resulting in a preferred up polarization.

The measurements were performed using two different kind of tips: NSC18 Cr–Au coated silicon tips from MikroMasch and B-doped diamond tips from NaDiaProbes. It is worth noting that the values are different when the measurements are performed with different kind of tips. The additional AFM-tip/ferroelectric interface itself modifies the built-in bias, so that the values measured are for the whole system including the ferroelectric layer, the surrounding layers and the electrodes/tip. It is then possible to compare the values obtained for different samples under the same conditions when using the same tip.

 1 If switching did not take place, for example if the contact between tip and sample was bad due to impurities on the sample surface or tip degradation, this routine will give random results. These points are therefore filtered out, and the mean and standard deviation of the remaining values are used to calculate the average built-in voltage of the sample under study.

The evolution of the built-in voltage has been studied as a function of the thickness of the SrTiO₃ layers, for two different series of samples, one with 50 nm thick PbTiO₃ layers, and one with 20 nm thick PbTiO₃ layers, and with two different kind of AFM tips, as reported in table [1](#page-4-0).

50 nm series

Figure [3](#page-5-0) shows the results for a series of four samples consisting of a 50 nm PbTiO₃ film with a top and/or bottom SrTiO₃ spacer of 2 nm (5 u.c.). The samples without a bottom spacer (A and D) are monodomain up, while those with a bottom spacer (B and C) are polydomain (up background with down nanodomains), independently of the top spacer, as shown in [[12](#page-12-2)].

A positive built-in voltage is observed for all the samples, consistent with the observed preferential direction of polarization. The built-in voltage correlates with the c-axis values measured via x-ray diffraction (see figure [3](#page-5-0)). Samples A and D are monodomain with a larger built-in voltage that results, under zero applied bias, in an increase in their polarization, associated with an increase of the c-axis due to polarization-strain coupling. On the other hand, samples B and C are polydomain, as a result of a stronger depolarization field that would be present in these samples if they were monodomain. In these samples, the built-in voltage is smaller, leading to a reduced piezoelectric distortion. Moreover, the domains with an up polarization would experience an increase in their c -axis, while the opposite domains would have their c -axis decrease. It is most certainly the presence of domain walls in the polydomain configuration that explains the observed reduced tetragonality, as domain walls are paraelectric and correspond therefore to a reduced distortion. As mentioned in [[12](#page-12-2)], Takahashi et al [[20](#page-12-9)] also observed such an increase of the c-axis lattice parameter for monodomain PbTiO₃ films grown directly on Nbdoped SrTiO₃ substrates compared to polydomain ones, upon using photochemical switching to induce the polydomain to monodomain transition.

20 nm series

The other series of samples is composed of a 20 nm $PbTiO₃ film with symmetric SrTiO₃ spaces of different$ thicknesses, from 0 up to 10 unit cells (see schematic representation in figure [4](#page-6-0)). These samples were shown to be monodomain for the samples with 0 and 1 unit cell of SrTiO₃ and polydomain for thicker spacers [[12](#page-12-2)]. Figure [4](#page-6-0) shows the built-in voltage measured with two different tips, a B-doped diamond tip (black dots) and a Cr/Au coated silicon tip (red squares). The results obtained with both kinds of tips demonstrate that the built-in voltage decreases for the sample with the thickest SrTiO₃ spacers. This observation can be compared to the study by Lu

Figure 3. Built-in voltage in the 50 nm PbTiO₃ series. Top: schematic representations of the four samples measured (A–D), with the PFM phase measurements showing the intrinsic domain configuration (A and D are monodomain, while B and C are polydomain) [[12](#page-12-2)], and an example of a switching loop obtained locally for each sample using a B-doped diamond tip. Bottom left: x-ray diffraction measurements for each sample (shifted for clarity), showing how the c-axis of the PbTiO₃ varies depending on the intrinsic domain configuration (from [[12](#page-12-2)]). Bottom right: measured built-in voltage, averaged over a large number of measurements as described in the text, versus c -axis of PbTiO₃. Both the built-in voltage and the c -axis clearly vary depending on the intrinsic domain configuration, with larger values for the monodomain samples compared to the polydomain ones.

et al [[21](#page-12-10)]: in BaTiO₃ thin films with SrRuO₃ top and bottom electrodes, they also observed a reduction of the built-in field by adding 2 unit cells of SrTiO₃ between the film and the top electrode. This was attributed to the symmetrization of the chemical interface termination sequence. The $RuO₂/BaO$ interface termination sequence occurring naturally at the top interface seems to be detrimental due to the presence of a pinned interface dipole arising from a mismatch between ionic radii. By adding the SrTiO₃ layer, the unfavorable interface termination is eliminated, leading to a stable and switchable ferroelectric polarization. The insertion of the SrTiO₃ also results in a further enhancement of the ferroelectric stability.

Our measurements additionally show that the built-in voltage measured with a Cr/Au coated silicon tip is systematically lower than that measured with a B-doped diamond tip, demonstrating the effect of the tip itself. Note that in the sample with the thickest SrTiO₃ spacer, the built-in voltage measured with the Cr/Au coated silicon tip is actually negative. Here the tip directly plays the role of top electrode, and changing the tip material results in different electrical boundary conditions, therefore affecting the total built-in voltage. The measured built-in voltage is then the sum of the built-in voltage in the sample and the one due to the tip, and depending on the tip material, can actually be negative.

Built-in voltage in samples with a top electrode layer

To study the effect of a top electrode layer, a sample similar to sample C in figure [3](#page-5-0) (50 nm PbTiO₃ film with top and bottom 2 nm SrTiO₃ spacers and with 22 nm bottom SrRuO₃ electrode on SrTiO₃ substrate) was grown, with the addition of an 11 nm top $SrRuO₃$ electrode layer sputtered in situ and then patterned to form squares of different sizes (the one used here is $100 \times 100 \ \mu \text{m}^2$).

PFM measurements were performed through the electrode, under different DC biases applied directly to the electrode, as described by Gruverman [[22](#page-12-11)] and used by different groups(e.g., [[23,](#page-12-12) [24](#page-12-13)]). In this case, we did not perform SSPFM measurements, as V_{DC} is applied to the whole electrode, so the whole area below switches at every cycle and each point in the grid will be affected by all the measurements performed before. Instead, the domain configuration underneath the electrode was monitored on 2 \times 2 μ m² scans by recording the phase and amplitude PFM response to a small AC voltage V_{AC} while applying a DC voltage V_{DC} to the tip and the top electrode layer. Figure [5](#page-7-0) (left) shows some of the phase images obtained on this sample with *V*_{AC} = 1 V. For $V_{\text{DC}} = 0$ V, the region below the electrode is mostly uniformly polarized, with the polarization oriented up (a). When increasing the voltage, down polarization domains appear (b)–(d), until the region is fully down polarized at $V_{\text{DC}} = 1.8$ V (e). When V_{DC} is then progressively decreased, up polarized domains appear in the down polarized background (f). These up domains grow until they cover most of the region (g)–(i), with only a few down domains left, until finally the region is fully monodomain up at $V_{\text{DC}} = -1$ V (j). Note also the difference between (c) and (f), both taken for $V_{\text{DC}} = 1 \text{ V}$, but one on increasing V_{DC} and the other on decreasing it.

From each image, it is possible to extract the switched area proportion which is taken as the number of pixels with a polarization pointing down divided by the total number of pixels. This gives a value of 1 for a fully down polarized region, and 0 for up. When plotted as a function of the voltage applied to the tip and top electrode layer V_{DC} , this results in a hysteresis loop as shown in figure [5](#page-7-0) (left; the values for the images (a)–(j) are reported directly on this graph, together with the values obtained for other scans not shown here). This hysteresis loop is shifted and shows a built-in voltage of 0.9 V. For comparison, the phase hysteresis loop and amplitude butterfly loops obtained on the same sample but without a top $SrRuO₃$ electrode are also shown in figure [5](#page-7-0) (right). For this sample, the built-in voltage is close to 0 V, and the PFM phase image obtained with $V_{\text{DC}} = 0$ V has a switched area proportion close to 0.5. This demonstrates that the presence of a top $SrRuO₃$ electrode induces a built-in voltage in a sample that does not have any otherwise.

In the hysteresis in figure [5](#page-7-0) (left), data points are displayed for different V_{AC} values. Even for very large V_{AC} (larger than the coercive voltage observed for this loop), the measurement does not seem to be affected. This can be explained by the fact that the PFM signals are recorded using the DART mode at a very high frequency

applied to the tip and top electrode layer. Switched area proportion (number of pixels with a polarization pointing down divided by the total number of pixels) versus V_{DC} , showing a large built-in voltage of 0.9 V in this sample (see supporting information). (Right) For comparison, a PFM phase image obtained at $V_{DC} = 0$ V on the same sample but without a top electrode layer is shown together with a phase hysteresis loop and an amplitude butterfly loop obtained by SSPFM with a B-doped diamond tip, showing a built-in voltage close to 0.

(typically 370 kHz), so that the effective voltage applied to the ferroelectric layer is reduced by the RC time constant of the circuit. The signal period is shorter than the observed minimum switching time in similar systems (100 μ s lower limit for one pulse switching in 270 nm thick PbZr_{0.2}Ti_{0.8}O₃ [[25](#page-12-14)]). This agrees with the work of Ivry *et al* [[26](#page-12-15)] where high-resolution PFM imaging is achieved by using a V_{AC} higher than the DC coercive voltage of the sample near the cantilever in-contact resonance frequency. Increasing the value of V_{AC} however can reduce the noise level in the PFM measurements.

Effect of built-in field on intrinsic domain configuration in samples without a top electrode layer

The effect of the built-in field can also be observed in the domain configuration of the samples without a top electrode. In [[12](#page-12-2)], PFM images revealed a drastic change in the intrinsic domain shape in our samples as a function of the SrTiO₃ spacer thickness as well as the PbTiO₃ film thickness.

50 nm series

In the series of samples with 50 nm $PbTiO₃$ films, the samples without a SrTiO₃ bottom spacer have a larger built-in voltage and are monodomain, while the two samples with a bottom $SrTiO₃$ spacers are polydomain with a reduced built-in voltage, as shown in figure [3.](#page-5-0) The built-in voltage results in a preferential polarization orientation that corresponds to the polarization direction of the monodomain samples, and to the direction of the polarization background for the polydomain samples.

20 nm series

In the series of samples with 20 nm PbTiO₃ films, the samples without $SrTiO₃$ spacers or with very thin (1 u.c.) ones are monodomain, while they become polydomain with SrTiO₃ spacer layers of 2 u.c. and more. The domains are more difficult to resolve in the polydomain samples in this series than in the 50 nm series. However, a gradual change of the phase can be seen as the SrTiO₃ spacer layer thickness increases (figure [6](#page-8-0)). To quantify this evolution, two reference regions were written by applying negative or positive DC bias to the tip, resulting in two square domains with well defined polarization oriented up or down. The mean phase in the as grown region can then be directly compared to that in the switched regions for this series of samples, as shown in figure [6.](#page-8-0) For the samples with thicker spacers, the mean phase of the as-grown region is significantly higher than 0° , meaning that more domains of opposite polarization are present in those samples, in agreement with the observations of a lower built-in voltage. However, none of the samples shows a mean phase in the as-grown region of more than 90°, corresponding to half up, half down. This is in line with our measurement of the built-in voltage, suggesting a preferred up polarization for all these samples.

Effect of built-in field on domain stability

To further discriminate between the effect of the built-in field and of the depolarization field, it is helpful to look at the back-switching of artificially written regions. There are several ways of studying domain wall dynamics in ferroelectric thin films. One of them is using time-resolved x-ray microdiffraction, as used by Grigoriev et al on

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 $Pb(Zr, Ti)O₃$ thin films to follow the polarization reversal after an electrical pulse, revealing a domain wall velocity of 40 m s^{−1} and a strong heterogeneity of the nucleation of reversed domains [[27](#page-12-16)]. Other approaches are based on direct imaging of the polarization state by PFM while a voltage is applied to the AFM tip used as a top electrode, or to a top electrode layer $[22–24]$ $[22–24]$ $[22–24]$ $[22–24]$ $[22–24]$. We have used PFM to follow the domain configuration and backswitching in different samples, both with and without a top electrode layer.

Without a top electrode layer

50 nm series

Figure [7](#page-9-0) shows PFM measurements obtained on the 50 nm PbTiO₃ film with 2 nm top and bottom SrTiO₃ interlayers. PFM measurements on the same 1.2 \times 1.2 μ m² region and under the same conditions were repeated after the area was first scanned with a DC bias applied to the tip (from −2.5 V up to +2.5 V as indicated in the figure). After applying a negative tip bias, the down polarized domains (white) shrink in size, while they expand after applying a positive tip bias. The images were not taken in that specific order, and although there is some spatial drift from one image to the other, it is possible to recognize and follow specific domains in their size alteration. Moreover, a noticeable relaxation of the domain size was observed after the poling, as shown in figure [8](#page-10-0), with a recovery of the initial configuration after a time of typically 3 h, showing that the position of the domain wall reproducibly relaxes back to its original position. These results demonstrate that it is possible to switch locally the polarization by applying a DC voltage between the AFM tip and the bottom electrode by moving the intrinsic domain walls, with a relaxation on a time scale suitable for measurements[.](#page-10-1)

20 nm series

Polarization back-switching was also studied in the series of samples with 20 nm PbTiO₃ films by using the same procedure as described above to follow the evolution of written regions as a function of time and are shown in [[12](#page-12-2)]. Measurements of the retention time of the written polarization (up and down) regions show a rather different mechanism for different SrTiO₃ spacer thicknesses. Without any SrTiO₃ spacer, the domain wall of the written structure moves and deforms with time, reducing the extension of the written region, but keeping the full amplitude of the switched region bounded by the domain wall. This mechanism can be explained by the presence of a built-in-field pushing towards a preferential orientation state, with the back-switching occuring at

Figure 8. Same measurements as in figure [7,](#page-9-0) but now showing the time evolution of the domains after the same area was first scanned either with +2.0 V_{DC} or with −2.5 V_{DC}. The images are numbered according to there acquisition after the area was first scanned with the specified voltage. The images were recorded with a speed of 0.5 Hz for 512 lines(∼17 min per scan), showing a complete recovery of the unpoled configuration after approximately 3 h. (See supporting information.)

layer. The horizontal scale is the measurement time, with a reading frequency of 1 Hz. The dotted red lines show the time at which the DC voltage is changed to the value indicated above.

the domain wall. On the other hand, with increasing thickness of the $SrTiO₃$ spacers, the back-switching mechanism is rather different with nano-domains appearing within the written region. This mechanism, changing a monodomain region towards a polydomain configuration, can be attributed to the depolarization field. For the sample with SrTiO₃ spacer layers of just 1 u.c., both effects can be seen: the roughening of the domain wall delimiting the written region as well as the appearance of opposite nano-domains inside, attesting that both mechanisms, i.e. the built-in voltage and the depolarization field, can play a role simultaneously.

With a top electrode layer

When adding a top electrode layer to these samples, we noticed that not only the domain configuration is changed and the loop is more shifted, but also the back-switching is much faster. To emphasize how quickly the change in polarization configuration occurs on a sample composed of a 50 nm PbTiO₃ film with 2 nm top and bottom SrTiO₃ interlayers and top (11 nm) and bottom (22 nm) SrRuO₃ electrodes, PFM phase is measured continuously along the same line (2 μ m length) (figure [9](#page-10-1)). While scanning, different DC voltages are applied to both the tip and top electrode layer. The horizontal scale is the measurement time, with a reading frequency of 1 Hz. The dotted red lines show the time at which the DC voltage is changed to the value indicated above. The domain configuration changes abruptly at each modification of the DC voltage, with almost no evolution as a function of time for a constant DC voltage. These measurements also show the uniform up polarization state for $V_{\text{DC}} < 0$ V and uniform down polarization state for $V_{\text{DC}} > 1$ V. This is in line with the shifted loop shown in figure [5](#page-7-0) for the same sample.

Note also that even upon complete switching, the opposite domains always start to nucleate at the same position, proving again the presence of strong nucleation sites, both for up and down domains. This is very much in line with the observations of Kim *et al* [[23](#page-12-12)] or Jesse *et al* [[28](#page-12-17)], who demonstrated the presence of preferential nucleation sites in $Pb(Zr, Ti)O₃$ capacitors using PFM measurements.

Conclusion

When working with ferroelectric ultrathin films, the boundary conditions are crucial to determine the properties of the ferroelectric layer. In this work, we have shown how it is possible to tune both the depolarization field and the built-in field by adding spacer layers between the ferroelectric film and the screening charges(electrode or surface adsorbates). SSPFM measurements revealed a progressive decrease of the built-in voltage as the thickness of the SrTiO₃ spacers increases. By increasing the thickness of the SrTiO₃ spacers layers sandwiching PbTiO₃ thin films, we were also able to tune the polarization configuration, gradually transitioning from a monodomain configuration with a preferential up polarization towards a polydomain one with downpolarized domains in an up-polarized background. The stability of the written regions was also affected by the $SrTiO₃$ spacer thickness, with a faster back-switching for the samples with the thicker $SrTiO₃$ spacers. Throughout this work, we have also compared series of samples with and without a top electrode layer, showing that a top SrRuO₃ electrode results in a stronger built-in voltage, responsible for a preferential monodomain configuration and a very fast (less than 1s) back-switching of oppositely written domains.

In view of recent work on controlling the dynamics of domains and domain walls by engineered pinning/ nucleation defects and electrode modification [[29](#page-12-18)–[34](#page-12-19)] for possible nanoelectronics applications, understanding the significant contribution of these boundary condition effects is especially useful. The simple method used here to control the domain structure and dynamics offers not only an excellent tool for fundamental studies of ferroelectric nanodomains and polarization stability in ferroelectrics but may also be used to enhance the dielectric properties of ferroelectric thin films by exploiting the large domain wall contributions to the dielectric permittivity [[35](#page-12-20)], for modulating the velocities of domain wall displacement [[34](#page-12-19)], or to engineer materials whose properties are dominated by the exotic functionalities that have recently been discovered at ferroic domain walls [[36](#page-12-21)]. We thus believe our work is extremely timely and will open an original new research direction within this large and technologically important field.

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